| Form PTO-1449  |             | U.S. Department of Commerce<br>Patent and Trademark Office  |                             | Attorney Docket No.<br>ARC920030009US1                                       | 1 -             | Serial No. Unassigned (0) |                       |  |
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| ,  |             | Patent and Trademark Office   |                             | Applicant (s): Robert Dennis Miller, et al.                                  |                 |                           |                       |  |
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<sup>&</sup>lt;sup>1</sup> Applicant's unique citation designation number (optional). <sup>2</sup> Applicant is to place a check mark here if English language Translation is attached.